Note: This Hwis a "tay model" of graphene. Desnot get at 1) Vallay degeneracy 2) 2D-1D nonorbobon 1) In graphene, we have a linear relationship between energy and momentum: $E = \frac{1}{V_F} k = \frac{1}{V_F} \sqrt{\left(\frac{k_x}{r}\right)^2 + \left(\frac{n_x\pi}{r}\right)^2} + \left(\frac{n_y\pi}{r}\right)^2} = \sum_{x} k = \frac{1}{V_F} E$

$$E = \overline{\psi}_F k = |\psi_F \sqrt{(k_x)^2 + (k_y)^2} = |\psi_F \sqrt{\left(\frac{x}{L_x}\right)} + \left(\frac{y}{L_x}\right) = \sum_{x \in \mathbb{Z}} k = \frac{1}{\sqrt{F}}$$

Derive the density of states vs. energy in graphene.
$$= \frac{dk}{dE} = \frac{1}{\sqrt{F}}$$

Now imagine you have a graphene nanoribbon. Ly is small. Calculate the density of states vs. energy of a 1d graphene nanoribbon.

$$E = \pi V f V K_{x}^{2} + K_{y_{0}}^{2} \quad k_{y_{0}} = L_{y}$$

1) $D(E) dE^* = D(U) dH$ $D(U) dK = \begin{bmatrix} \frac{1}{(T/L)^2} \times 2 & (pin) \end{bmatrix} \times area of disk. I valius K$ in K-space $k \times 70 & ky > 0$ $= \begin{bmatrix} \frac{1}{(T/L)^2} \times R \end{bmatrix} Z T K dK = L^2 \frac{1}{T} \frac{E}{NF} dK$ $= L^2 \frac{1}{T} K dK = L^2 \frac{1}{T} \frac{E}{NF} dK$ $D(E) = D(K) \frac{dK}{dE} = \begin{bmatrix} L^2 \frac{1}{T} E \frac{1}{NF} \frac{1}{NF} \end{bmatrix}$ $\int (E) = D(K) \frac{dK}{dE} = \begin{bmatrix} L^2 \frac{1}{T} E \frac{1}{NF} \frac{1}{NF} \end{bmatrix}$

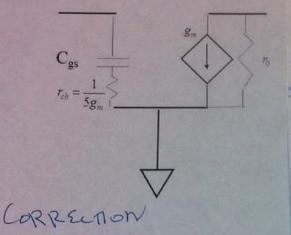
$$\begin{split} \mathcal{D}(E) dE &= \mathcal{D}(u) \mathcal{D}(u) \\ &= \left[\frac{1}{\pi L} \times 2 \left(\frac{1}{5} ph \right) \right] \times distance in k-space between k, ktdle \\ &= \frac{1}{\pi L} \times dL = \mathcal{D} \left(\mathcal{U} \right) = L \stackrel{2}{\pi} \\ &= \mathcal{D}(E) = \mathcal{D}(u) \frac{dk}{dE} = L \stackrel{2}{\pi} \stackrel{1}{t} \\ &= \mathcal{D}(E) = \mathcal{D}(u) \frac{dk}{dE} = L \stackrel{2}{\pi} \stackrel{1}{t} \\ \end{split}$$

3)Which metal would you pick for a low resistance contact to n-type charge carriers in a semiconducting carbon nanotube: Large work function, or small work function? Why?

n-type means we want Fermi energy of contact in the conduction band, i.e. closer to the vacuum energy than away... So we want a LOW work function metal to make low contact resistance to the n-type branch....

3) For the circuit below, find the y-matrix. Next, fin terms of the circuit elements. Find f_T and f_{Max} .

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c = <u>(921-912)</u> -Reyn)Ry20)-Reyn)R.900 - 9m2 4 to Re (53+ + 300 (93)) Im²ro/le(- jwigesgn (59m-jwigs)) 4/le(- (59m+jwicss)(59m-jwigs)) 5. = $\frac{3^{2}r^{2}}{4}/\frac{1}{4}\left(\frac{1-1}{(52r)^{2}}+\frac{(wG_{3})^{2}}{(52r)^{2}}\right)^{2}$ = <u>gmrs</u> (59m)² + (w(ss)² 4 (w(ss)² 5gm topts 9mr. 20w2 (22 (25gm2 + w2 (32))

$$U = \frac{g_{m}v_{o}}{2\sigma\omega^{2}(g_{s}^{2})} \left(25g_{m}^{2} + \omega^{2}(g_{s}^{2})\right)$$

$$\begin{split} \mathcal{U} \Big|_{F_{mAX}} &= 1 \\ I &= \frac{g_m Y_{\circ}}{20 C_{gs}^2 \omega_{mAX}^2} \left(25 g_m^2 + \omega_{mAX}^2 (g_s^2) \right) \\ I &= \frac{g_m Y_{\circ}}{20 C_{gs}^2 \omega_{mAX}^2} \left(25 g_m^2 + \omega_{mAX}^2 (g_s^2) \right) \\ I &= \frac{g_m Y_{\circ}}{20} = \frac{25}{20} g_m Y_{\circ} \frac{g_m^2}{g_s^2 \omega_{mAX}^2} \left(-\frac{g_m Y_{\circ}}{20} \right) \\ \mathcal{W}_{mAX}^2 &= \frac{25}{20} g_m Y_{\circ} \frac{g_m^2}{G_{gs}^2 \omega_{mAX}^2} \left(-\frac{g_m Y_{\circ}}{20} \right) \\ \mathcal{W}_{mAX} &= 5 g_m \sqrt{g_m Y_{\circ}} = 2\pi f_{mAX} \end{split}$$